

Abstract Submitted  
for the MAR07 Meeting of  
The American Physical Society

**The ferroelectric to antiferroelectric transition in multiferroic  $\text{BiFe}_{1-x}\text{Cr}_x\text{O}_3$  epitaxial films**<sup>1</sup> DAE HO KIM, HO NYUNG LEE, MARIA VARELA, HANS M. CHRISTEN, Materials Science and Technology Division, Oak Ridge National Laboratory, Oak Ridge, TN — With the renewed interest in multiferroics, intensive investigations on  $\text{BiFeO}_3$  films have enhanced the understanding of the nature of the ferroelectricity and the weak parasitic ferromagnetism. In contrast, despite having similar structural and chemical properties as  $\text{BiFeO}_3$ , little is known about  $\text{BiCrO}_3$ , due to the difficulty of synthesizing single-phase material. We have grown high quality  $\text{BiCrO}_3$  epitaxial films by pulsed laser deposition and revealed that they exhibit antiferroelectricity with an electric-field induced ferroelectric phase. This antiferroelectricity is consistent with the picture of the Bi lone pair inducing polarization in bismuth-based perovskites. Furthermore, we have grown  $\text{BiFe}_{1-x}\text{Cr}_x\text{O}_3$  solid-solution epitaxial films from  $\text{BiFeO}_3$  and  $\text{BiCrO}_3$  targets and observed a ferroelectric to antiferroelectric transition with increasing the Cr content. The interplay between the structural and (anti) ferroelectric properties and the role of the epitaxial strain will be discussed.

<sup>1</sup>Research sponsored by the Division of Materials Sciences and Engineering, Office of Basic Energy Sciences, U.S. Department of Energy, under contract DE-AC05-00OR22725 with Oak Ridge National Laboratory, managed and operated by UT-Battelle, LLC.

Daeho Kim  
Materials Science and Technology Division,  
Oak Ridge National Laboratory, Oak Ridge, TN

Date submitted: 30 Nov 2006

Electronic form version 1.4